

Supporting Information

Hydrothermally derived p-n MoS₂-ZnO from p-p MoS₂-ZIF-8 for efficient detection of NO₂ at room temperature

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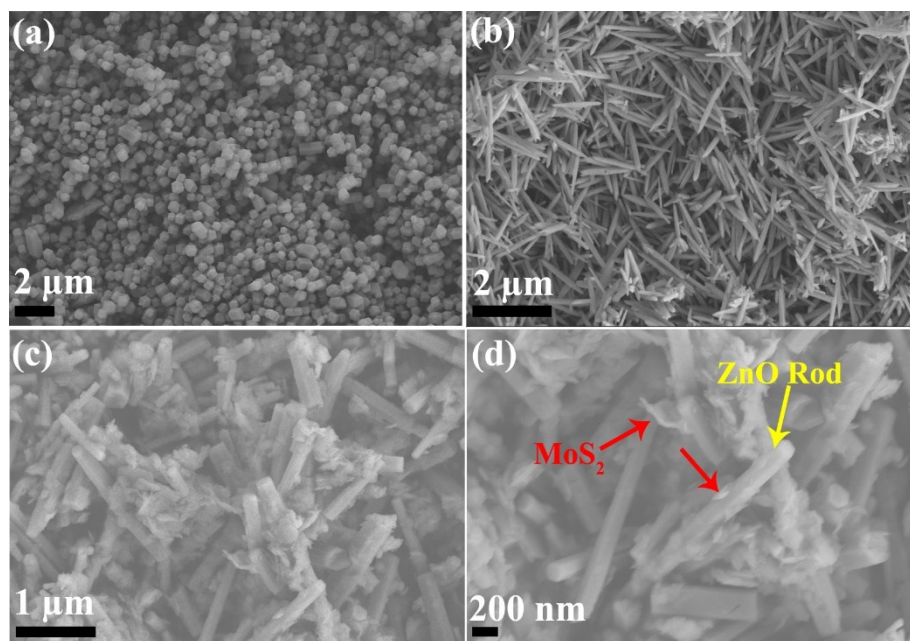


Figure S1. SEM images of (a) pure ZIF-8; (b) pure ZnO rods; and (c, d) MZR heterostructure

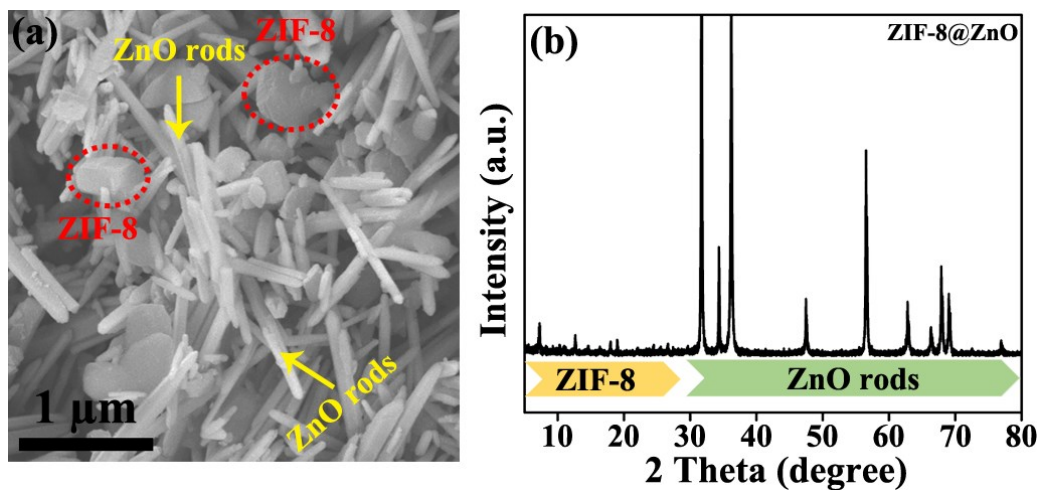


Figure S2. (a, b) SEM and XRD of ZIF-8@ZnO composites which was heating at 120 $^{\circ}\text{C}/2\text{h}$ hydrothermally.

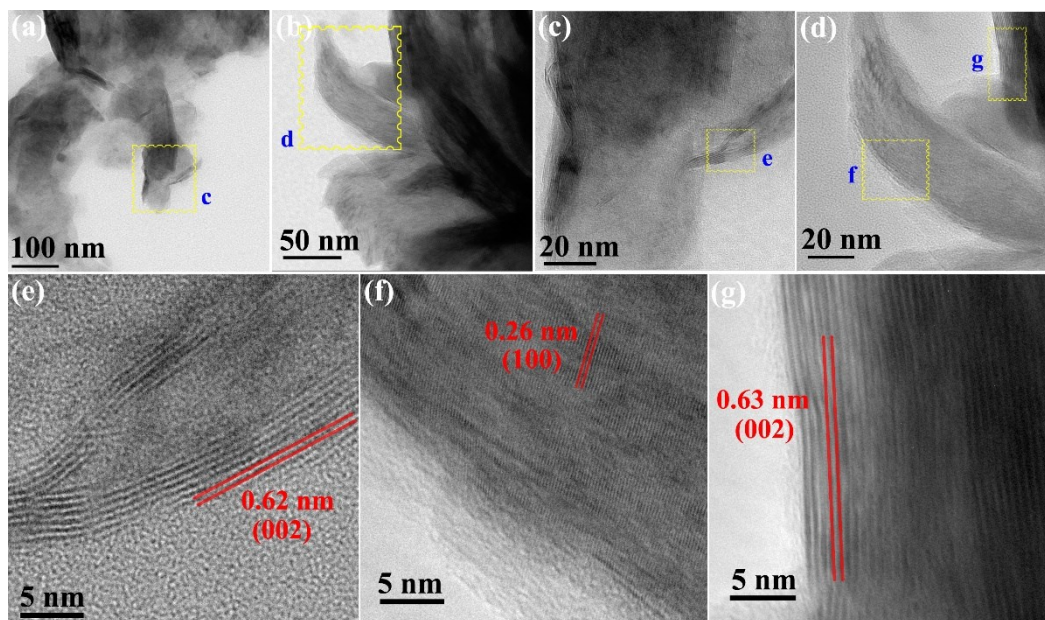


Figure S3. (a-d) TEM images; (e-g) HRTEM images of pristine MoS₂ NSs.

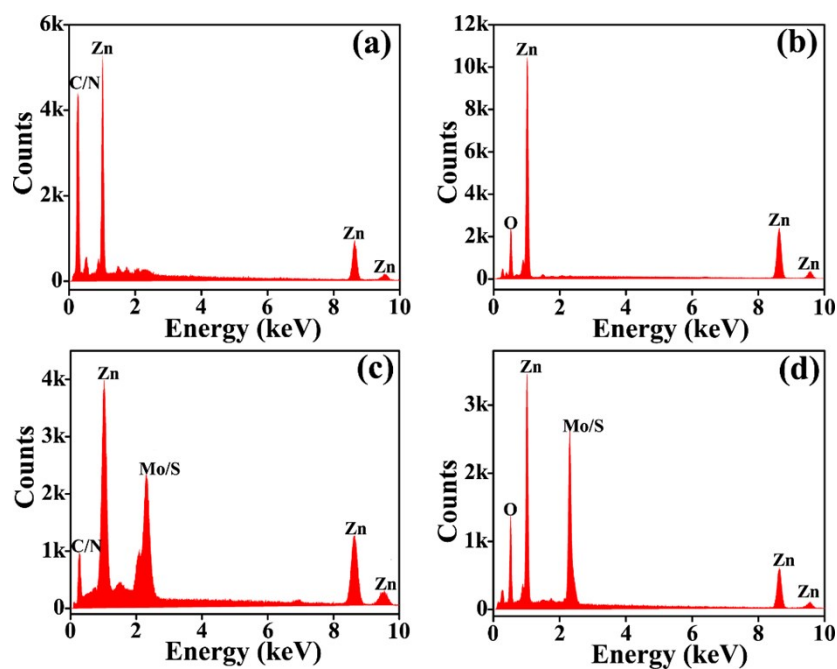


Figure S4. EDS spectra of (a) pure ZIF-8; (b) pure ZnO rods; (c) MoS₂@ZIF-8; (d) MoS₂@ZnO heterostructure.

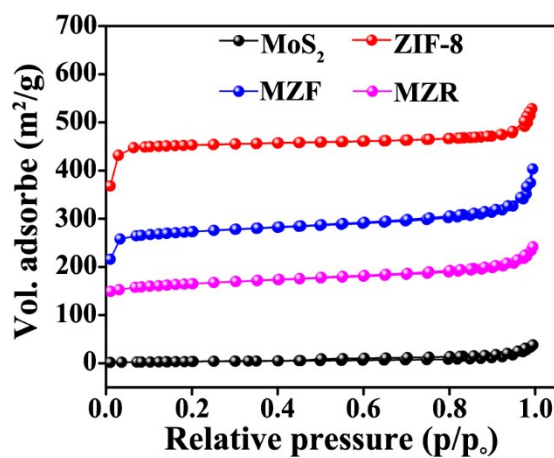


Figure S5. N₂ adsorption-desorption isotherms of the samples; the changes in the starting values in the y-axis for MoS₂, MZR, MZF, and ZIF-8 are 1.7, 147, 213, and 365 m²/g respectively.

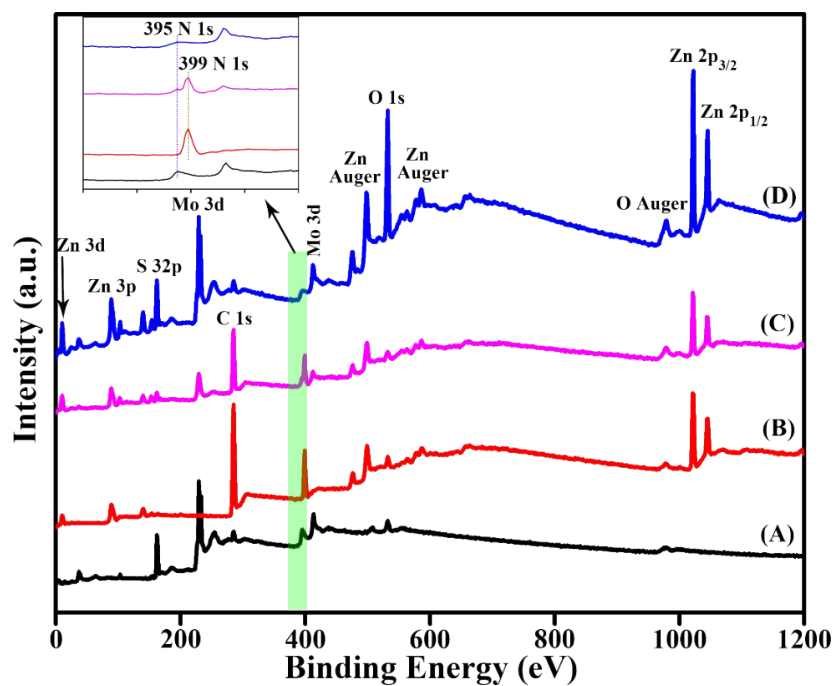


Figure S6. XPS survey spectra of MoS₂ (A), ZIF-8 (B), MZF (C), MZR (D); Insert figure shows that there are two N 1s peaks, one at 395 eV and one at 399 eV. The first one is due to the adsorption of N₂ gas on the surface of MoS₂ as it was heated at 600 °C/4h under nitrogen atmosphere, while the second is due to the ligand nitrogen only in pure ZIF-8 and MZF, which was eliminated after heating at 150 °C in MZR.

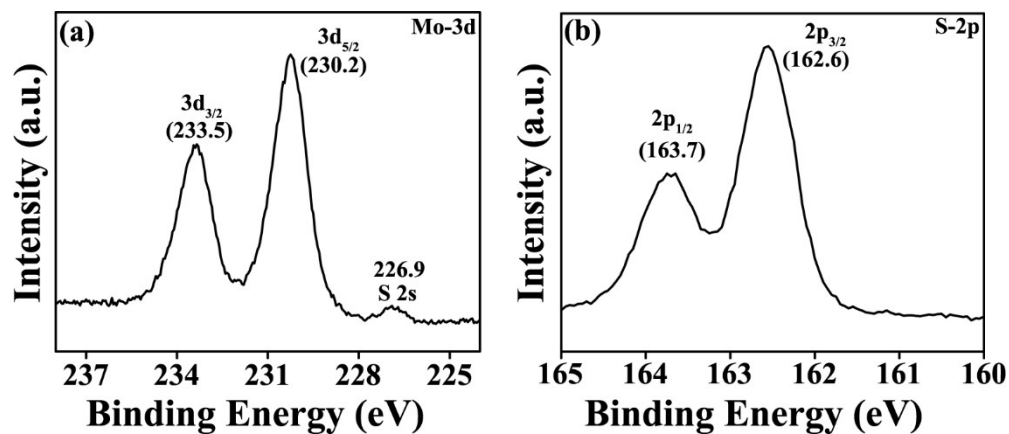


Figure S7. High resolution XPS spectra of Mo, and S of the pure MoS₂ NSs.

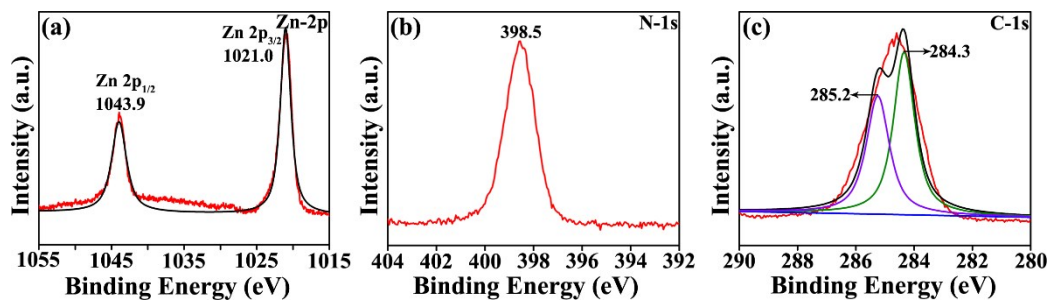


Figure S8. High resolution XPS spectra of pure ZIF-8; (a) Zn 2p, (b) N 1s, (c) C 1s.

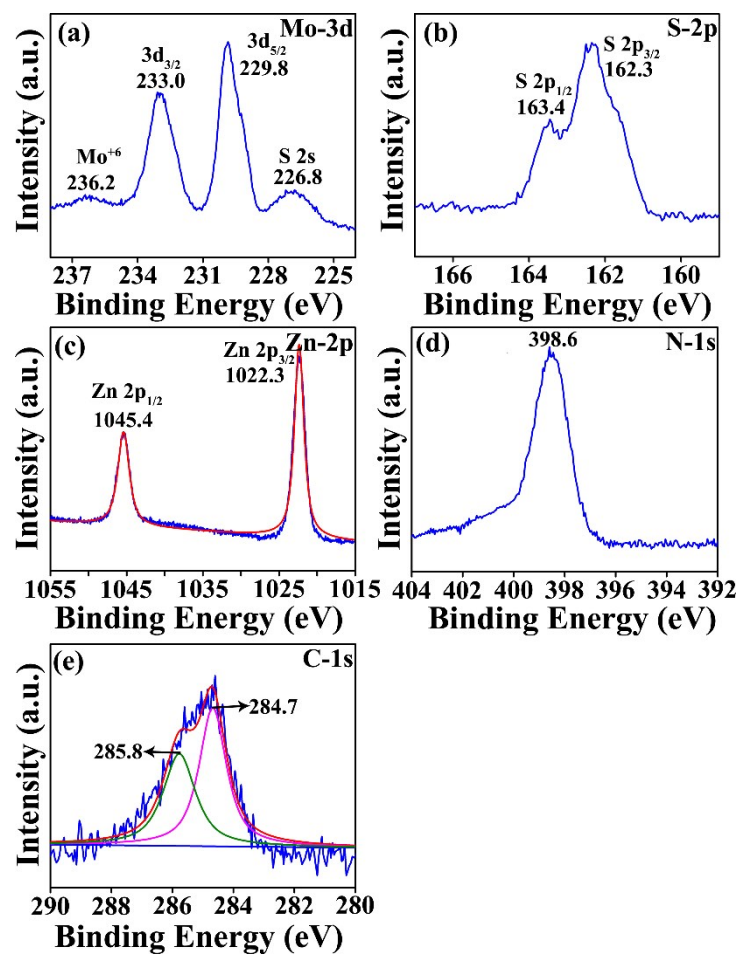


Figure S9. High resolution XPS spectra of MZF heterostructure; (a) Mo 3d, (b) S 2P, (c) Zn 2p, (d) N 1s, (e) C 1s.

Table S1. Comparative XPS Peak position of the pure MoS₂, ZIF-8 with MZF and MZR composites.

Samples	Binding Energy (eV)		
	Mo (3d _{3/2} /3d _{5/2})	S (2p _{1/2} /2p _{3/2})	Zn (2p _{1/2} /2p _{3/2})
MoS ₂	233.5/230.2	163.7/162.6	---/---
ZIF-8	---/---	---/---	1043.9/1021.0
MZF	233.0/229.8	163.4/162.3	1045.4/1022.3
MZR	232.8/229.6	163.5/162.4	1045.1/1022.0

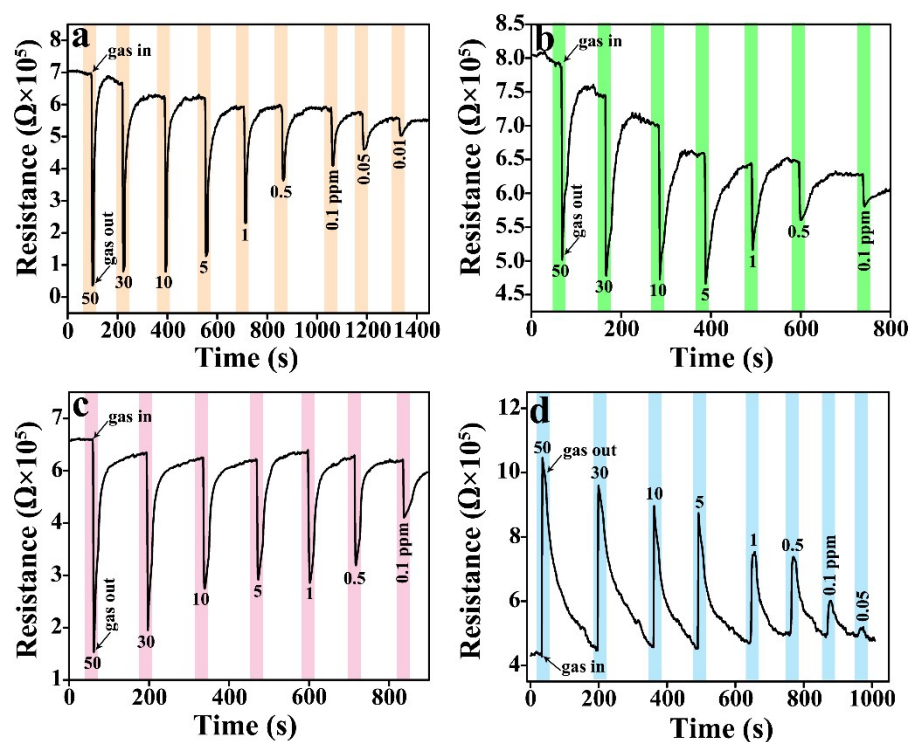


Figure S10. Dynamic response transient of (a) MZF; (b) pure MoS₂; (c) pure ZIF-8; (d) pure ZnO rods.

Table S2. Response and response/recovery times in seconds all of the sensors towards NO₂ gas at RT.

Sensors	MoS ₂			ZIF-8			ZnO			MZR			MZF		
NO ₂ (ppm)	R	<i>t_{res}</i>	<i>t_{rec}</i>	R	<i>t_{res}</i>	<i>t_{rec}</i>	R	<i>t_{res}</i>	<i>t_{rec}</i>	R	<i>t_{res}</i>	<i>t_{rec}</i>	R	<i>t_{res}</i>	<i>t_{rec}</i>
50	1.58	3.2	41.0	3.65	2.8	50.6	5.06	3.1	86.4	34.91	1.5	30.9	19.56	2.1	40.9
30	1.52	3.8	39.4	2.74	4.3	49.6	3.14	3.5	83.8	31.27	1.9	28.8	8.35	3.0	35.7
10	1.48	4.6	35.7	2.15	5.8	50.1	2.44	4.7	75.2	29.52	2.1	25.6	7.81	3.6	34.3
5	1.37	5.8	33.1	1.77	6.3	42.1	2.29	6.1	69.3	24.85	3.2	22.4	4.86	5.3	29.7
1	1.24	7.2	30.1	1.88	8.2	40.5	1.63	7.0	55.2	9.49	4.8	18.0	2.55	6.2	21.3
0.5	1.15	7.9	26.2	1.65	8.7	38.9	1.51	8.1	47.4	4.57	6.3	16.5	1.64	7.1	18.8
0.1	1.08	11.4	21.4	1.25	10.4	35.7	1.18	9.9	41.6	1.67	8.0	15.4	1.44	9.5	15.9
0.05							1.04	11.3	24.9	1.41	8.6	13.3	1.24	10.3	14.2
0.01										1.05	11.2	10.2	1.01	12.6	12.6
R-Response <i>t_{res}</i>-response time in seconds <i>t_{rec}</i>-recovery time in seconds															

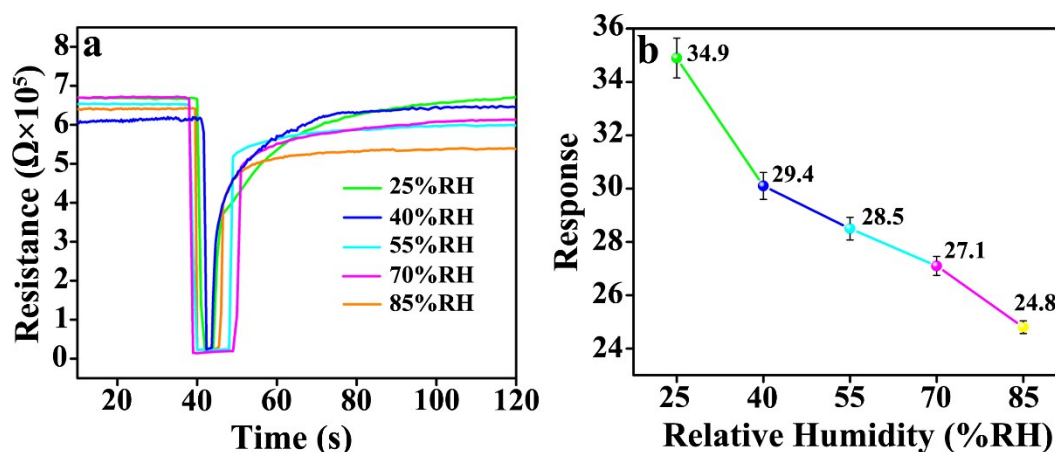


Figure S11. (a) Dynamic response transient of MZR to 50 ppm NO_2 at different relative humidity (RH) at RT; (b) Response of the sensor corresponding to Figure (a).

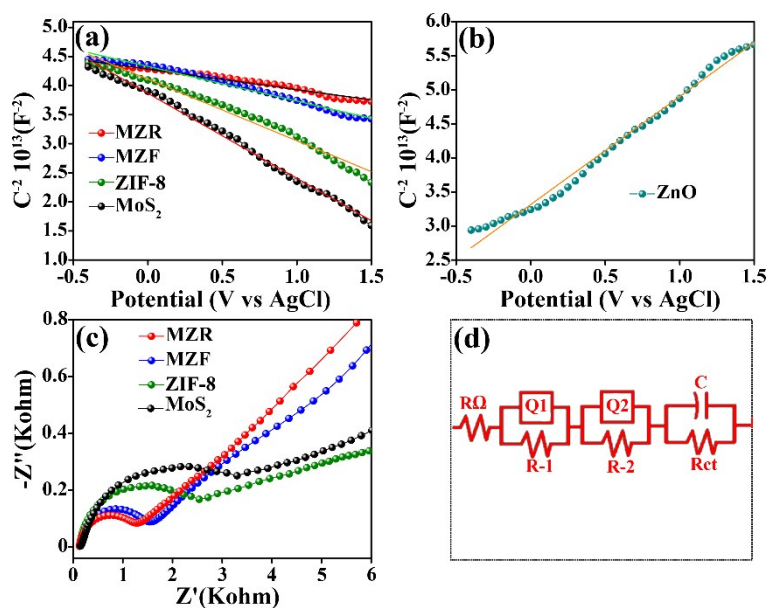


Figure S12. (a) The comparative MS plots of the pristine MoS_2 NSs, ZIF-8, with MZF and MZR; (b) MS plot of pure ZnO; (c, d) Nyquist plots of the composites compared with bare MoS_2 and ZIF-8; (d) equivalent circuit model (Measurement in the solution of 5 mM $\text{Fe}(\text{CN})_6^{3-/4-}$ containing 0.1 M KCl).

The electrochemical impedance spectroscopy (EIS) was performed by using CHI660E series electro-chemical workstation (Shanghai Chenhua Instrument Co., Ltd., China), with a three-electrode system. The working electrode is glass carbon electrode (GCE) coating with the as-synthesized samples. A silver/silver chloride (Ag/AgCl) served as reference electrode and platinum (Pt) sheet was used as a counter electrode. All three electrodes were vertically immersed in a solution of 5 mM $\text{Fe}(\text{CN})_6^{3-/4-}$ (1:1) containing 0.1 M KCl to analyze the electrochemical performance of the modified electrode as shown in Figure S10 c. The testing frequency ranges from 10^3 to 0.1 Hz at 10-mV amplitude.

Table S3. Fitted impedance parameters of the samples.

Samples	MoS ₂	ZIF-8	MZR	MZF
R_{Ω} (Ω)	1109.2	988.1	693.3	727.8
R_{ct} (Ω)	10004	8504	4257	6731

Table S4. Comparative gas sensing performance of MoS₂@ZnO heterostructure with reported work

Sensing materials	NO ₂ (ppm)	Temp. (°C)	Response	t_{res}/t_{rec} (s)	LOD (ppm)	Synthesis technique	Refs.
MoS ₂ hollow sphere	100	150	40.5%	79/225	0.5	hydrothermal method	[1]
Exfoliated MoS ₂	1.0	200	5.80	2460/2340	0.02	Chemical Exfoliation	[2]
2D MoS ₂	50	RT	300%	180/480	25	chemical vapor deposition	[3]
Mixed MoS ₂ flakes	10	RT/UV	10.36%	8.51/---	10	chemical vapor deposition technique	[4]
MoS ₂ /ZnO	50	200	31.2%	---/---	0.2	Sputtering	[5]
MoS ₂ /SnO ₂	5	RT	18.7	---/---	0.25	Hydrolysis process	[6]
MoS ₂ /ZnO	5	RT	3050%	40/1000	0.05	Wet chemical route	[7]
MoS ₂ /ZnO	0.2	RT/N ₂ (UV)	188%	---/---	0.05	Sonication	[8]
MoS ₂ /MoO ₃	10	RT	33.6%	19/---	10	vapor deposition process	[9]
MoS ₂ /SnO ₂	10	RT	~ 29 %	408/162	0.5	Chemical Exfoliation/ Annealing	[10]
ZnSe/ZnO	8	200	10.42	98/141	1.0	Thermal Oxidation	[11]
ZnO/rGO	2.5	110	33.11	182/234	0.05	Solvothermal method	[12]
rGO-ZnO	5	80	1.26	165/499	1.0	Thermal stirring	[13]

nanoparticles							
ZnO/rGO nanowalls	5	RT/UV	3.5	25/15	5.0	Thermal reduction/soft solution process	[14]
MoS ₂ @ZnO heterostructure	50	RT	34.91	1.5/30.9	0.01	Ultrasonic/Hydrothermal process	Present work

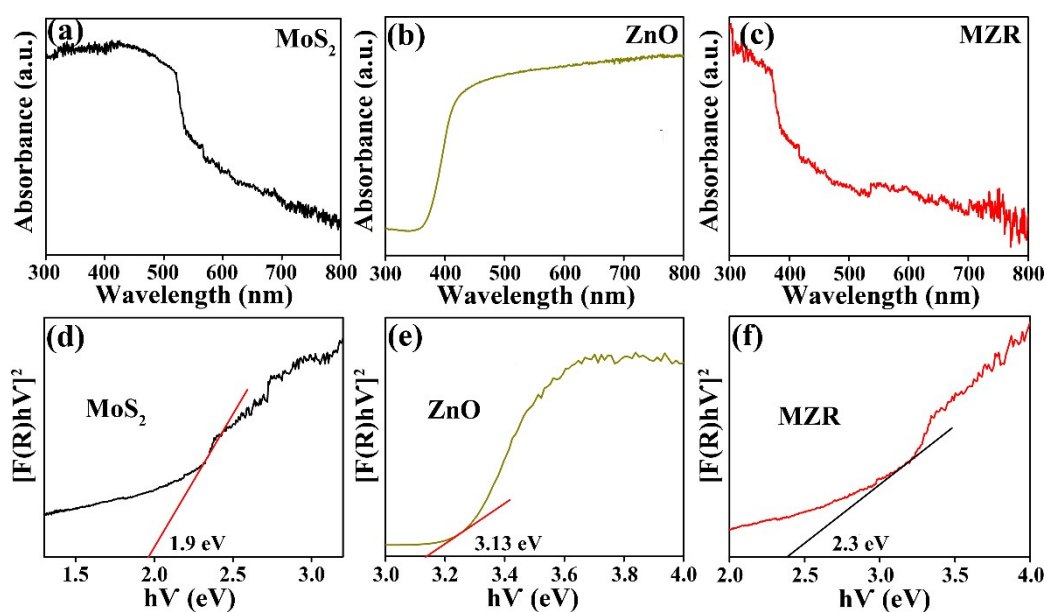


Figure S13. (a-c) UV visible diffused reflectance spectra and (d-f) corresponding plots of transformed Kubelka-Munk versus the energy light of the samples.

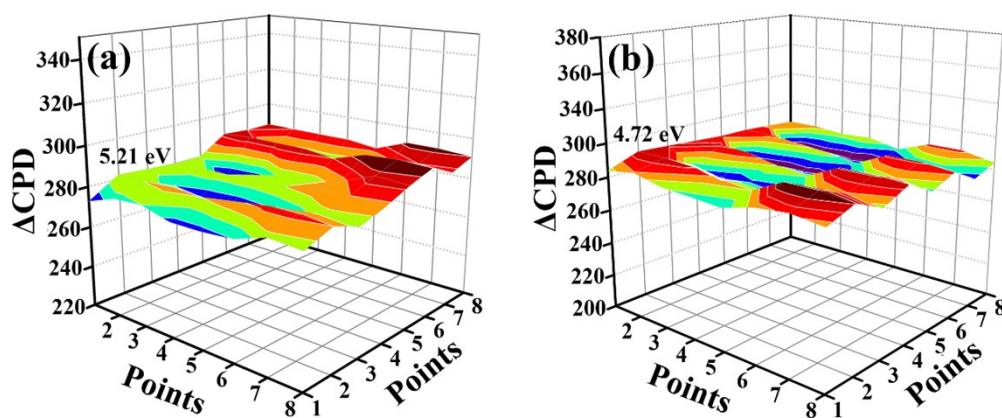


Figure S14. Kelvin probe of (a) MoS₂ NSs, and (b) ZnO rods.

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